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CONFIRMATION NO. FIRST NAMED INVENTOR ATTORNEY DOCKET NO. APPLICATION NO. FILING DATE FIS920010024US1 04/30/2001 Basanth Jagannathan 09/843,783 04/07/2003 32074 7590 INTERNATIONAL BUSINESS MACHINES CORPORATION **EXAMINER** DEPT. 18G COLEMAN, WILLIAM D BLDG. 300-482 2070 ROUTE 52 PAPER NUMBER ART UNIT HOPEWELL JUNCTION, NY 12533 2823 DATE MAILED: 04/07/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

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e considered timely. ailing date of this communication. U.S.C. § 133). reduce any	
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CFR 1.85(a). by the Examiner.	
or (f).	
o this National Stage	
a provisional application).	

	Application N .	Applicant(s)	
. Office Action Summers	09/843,783	JAGANNATHAN ET AL.	
Office Action Summary	Examiner	Art Unit	
-	W. David Coleman	2823	
The MAILING DATE f this communication appears on the cover sheet with the correspondence address Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).  Status			
1) Responsive to communication(s) filed on <u>07 Ja</u>	anuary 2003 .		
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ This	s action is non-final.		
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.  Disposition of Claims			
4) Claim(s) 1-15 is/are pending in the application.			
4a) Of the above claim(s) 10-14 is/are withdrawn from consideration.			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-9 and 15</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/or election requirement.			
Application Papers			
9)☐ The specification is objected to by the Examiner.			
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.			
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).			
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.			
If approved, corrected drawings are required in reply to this Office action.			
12)☐ The oath or declaration is objected to by the Examiner.			
Priority under 35 U.S.C. §§ 119 and 120			
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).			
a) ☐ All b) ☐ Some * c) ☐ None of:			
•	1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents	have been received in Application	on No	
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>			
14) Acknowledgment is made of a claim for domestic	•		
a) The translation of the foreign language provisional application has been received.  15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.			
Attachment(s)			
Notice of References Cited (PTO-892)  Notice of Draftsperson's Patent Drawing Review (PTO-948)  Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal P	(PTO-413) Paper No(s) atent Application (PTO-152)	
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#### **DETAILED ACTION**

## Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on January 7, 2003 has been entered.

### Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-9 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Czubatyj et al., U.S. Patent 5,180,690 in view of Furukawa et al., U.S. Patent 4,885,614.
- 4. Pertaining to claims 1 and 15, <u>Czubatyj</u> discloses a semiconductor process substantially as claimed. <u>Czubatyj</u> teaches Applicants disclosure. Czubatyj discloses a semiconductor process as claimed. Czubatyj teaches a method of reducing film growth rate when growing a carbon-or boron-doped silicon film or silicon-germanium film comprising:

carbon or boron-doping while supplying a silicon precursor (column 11, line 16) and (column 4, line 40) to a substrate, at reduced pressure of about 0.1 to 100 millitor (column 11,

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line 23), at a temperature of below about 800<sup>0</sup>C. (column 5, line 35), wherein said step of doping while supplying includes supplying a dopant precursor from a single source to the substrate. However, Czubatyj does not specifically disclose lowering the flow rate of the silicon precursor, whereby a concentration of the dopant in the substrate increases.

<u>Furukawa</u> teaches a doping concentration as disclosed in Applicants (FIG. 2), i.e., 10<sup>19</sup> cm<sup>3</sup>(column 4, line 41). In view of <u>Furukawa</u>, it would have been obvious to one of ordinary skill in the art to incorporate the doping concentrations of <u>Furukawa</u> into the <u>Czubatyj</u> semiconductor process because the process will exhibit a high current gain transistor (column 4, lines 61-63).

- 5. Pertaining to claim 2, <u>Czubatyi</u> teaches wherein supplying germanium precursor to the substrate (column 3, line 53).
- 6. Pertaining to claim 4, <u>Czubatyj</u> teaches wherein the doping is at a temperature of less than 8000C (column 7, lines 22-25).
- 7. Pertaining to claim 5, 6 and 7, <u>Czubatyj</u> discloses a semiconductor process substantially as claimed as discussed above. However, <u>Czubatyj</u> fails to disclose wherein the dopant is carbon and wherein the carbon doping is by a carbon precursor supply that is a single source. <u>Furukawa</u> teaches a single source carbon doping gas (Example 6). In view of <u>Furukawa</u>, it would have been obvious to one of ordinary skill in the art to incorporate a single source carbon doping gas into the <u>Czubatyj</u> semiconductor process because the process forms a doped silicon-germanium-carbon layer simultaneously (column 9, lines 45-49).
- 8. Pertaining to claims 3, 8 and 9 the combined teaches fail to disclose the ranges as claimed for the process of reducing film growth rate when growing carbon or boron-doped silicon film or

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silicon-germanium film. Given the teaching of the references, it would have been obvious to determine the optimum thickness, temperature as well as condition of delivery of the layers involved. See *In re Aller, Lacey and Hall* (10 USPQ 233-237) "It is not inventive to discover optimum or workable ranges by routine experimentation. Note that the specification contains no disclosure of either the critical nature of the claimed ranges or any unexpected results arising therefrom. Where patentability is said to be based upon particular chosen dimensions or upon another variable recited in a claim, the Applicant must show that the chosen dimensions are critical. *In re Woodruff*, 919 f.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Any differences in the claimed invention and the prior art may be expected to result in some differences in properties. The issue is whether the properties differ to such an extent that the difference is really unexpected. *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986)

Appellants have the burden of explaining the data in any declaration they proffer as evidence of non-obviousness. *Ex parte Ishizaka*, 24 USPQ2d 1621, 1624 (Bd. Pat. App. & Inter. 1992).

An Affidavit or declaration under 37 CFR 1.132 must compare the claimed subject matter with the closest prior art to be effective to rebut a prima facie case of obviousness. *In re Burckel*, 592 F.2d 1175, 201 USPQ 67 (CCPA 1979).

#### Conclusion

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to W. David Coleman whose telephone number is 703-305-0004. The examiner can normally be reached on 9:00 AM-5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 703-306-2794. The fax phone numbers for the

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organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7721 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

W. David Coleman

Examiner Art Unit 2823

WDC April 2, 2003